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	Application Number		10588981		
	Art Unit		2006-08-10		
			ERICK BOSWELL		
			2881		
			YET ASSIGNED		
			F146		

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Filing Date		2006-08-10		
First Named Inventor	RODE	ERICK BOSWELL		
Art Unit		2881		
Examiner Name	NOT '	YET ASSIGNED		
Attorney Docket Number		F146		

	LEUNG, KA-NGO, "Plasma sources for electrons and ion beams," J. Vac. Sci, Technology B, Nov/Dec 1999, Vol. 17 No. 6., pages 2776-2778.						
	MATHEW, JOSE V., ET AL., "Subcutoff microwave driven plasma ion sources for multielemental focused ion beam systems," Review of Scientific Instruments, 2008,Vol 79, 5 pages.						
	3 ONO, L.K., ET AL., "A Compact Gas Cluster Ion Beam Source of QSEC," 2003, 4 pages.						
	4 Singletron Acceletor Systems: Coaxial and In-Line Positive Ion Accelerators, 6 pages.						
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